

[Inicio](#) > Thermal and oxidation stability of Ti_xW_{1-x} diffusion barriers investigated by soft and hard x-ray photoelectron spectroscopy

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URL: <https://aip.scitation.org/doi/10.1063/5.0048304>

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Research Lines: [Ab-Initio Electronic Structure Methods](#)

Publication: Journal of Applied Physics

Place Published: AIP

Volume / Number: 129 / 195302

Palabras clave: [Density functional theory](#), [Ti](#), [W](#), [XPS](#)

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Source URL (retrieved on 17 Jul 2024 - 19:29): <https://www.bsc.es/es/research-and-development/publications/thermal-and-oxidation-stability-tixw1%E2%88%92x-diffusion-barriers>